

Study of charge dynamics in transparent single-walled carbon nanotube films

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We report the transmission over a wide frequency range (far infrared–visible) of pristine and hole-doped, free-standing carbon nanotube films at temperatures between 50 K and 300 K. Optical constants are estimated by Kramers-Kronig analysis of transmittance. We see evidence in the far infrared for a gap below 10 meV. Hole doping causes a shift of spectral weight from the first interband transition into the far infrared. Temperature dependence in both the doped and undoped samples is restricted to the far-infrared region.

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I. INTRODUCTION

As carbon nanotubes attract more and more attention for use as electronic materials, so grows the need for the accurate determination of their fundamental electrical and optical properties. However, for practical reasons, these properties are not easy to determine. The optical response of a carbon nanotube depends on the tube diameter, chirality, and orientation. Bulk samples, as well as thin films, are made up of many tube types which differ in the values of these parameters. In addition the samples have a rough surface, contain void space and have variability regarding the interaction between tubes, *e.g.* the strength of intertube hopping. Despite these less than ideal properties, applications exist where single-walled carbon nanotube (SWNT) thin films offer superior performance to other materials.¹ In this paper we present the frequency-dependent optical functions determined from transmission through high-quality free-standing nanotube films in a wide frequency and temperature range, followed by Kramers-Kronig analysis of transmittance.

Nanotube optical properties have been studied by a number of researchers. Some studies^{2,3} have been restricted to photon energies between 0.5–3 eV. Other measurements^{4,5,6} have included lower frequencies, where metallic tubes exhibit free-carrier absorption. Studies in the low frequency range also allow one to test the prediction that certain tubes would have very small gaps.^{7,8,9} These gaps have been reported near 10 meV, with substantial variation from sample to sample.^{4,5,6}

Our measurements improve on earlier reports^{4,5,6,10,11,12} in several ways. Thick films used for reflectance measurements^{4,5,10} had poor surface quality. Transmission of films deposited on substrates⁶ required the use of several different substrate materials, making normalization difficult; moreover, temperature studies in this configuration are hindered by the thermal properties of the substrates. Transmission studies¹¹ of free-standing nanotube films found evidence for free-carrier response

TABLE I: Processing details of the samples studied.

ID	Thickness(nm)	Processing	
		temperature (°C)	time (h)
A	250	as-prepared	
B	250	1000	12
C	150	as-prepared	
C'	150	1000	12

down to 50 meV but were not analyzed for optical constants. We present here measurements over a wide frequency range on free-standing samples, studying both the temperature dependence and the redistribution of carriers upon doping.

II. EXPERIMENTAL PROCEDURES

Film preparation, starting from laser-ablated SWNT's of 1.37 nm mean diameter,¹³ was described in Ref. 1. Details of processing for the samples are given in Table I. The sample thicknesses were determined by AFM measurements. Samples A and C were measured as prepared (“unbaked”). Thermal processing (“baking”) consisted of treating the samples in flowing pure argon at 1000° C for 12 hours, to remove from the sample the nitric acid, used during purification.^{6,12} Sample B was a second piece of the same film as Sample A; samples C and C' were the same piece of film measured both before and after baking. Spectra were taken on three different spectrometers with sufficient spectral overlap to allow unambiguous merging of transmittance curves: a Bruker 113v Fourier-transform interferometer (20–3000 cm⁻¹) with a Si bolometer (FIR) and a DTGS detector (MIR), a home-made near infrared/visible/UV spectrometer based on a Perkin-Elmer monochromator (2000–40000 cm⁻¹), and a Perkin-Elmer Lambda 900 VIS/UV spectrometer. Temperature-dependent measurements were conducted

with the first two instruments in a flowthrough He cryostat with polyethylene and KBr windows, respectively. The polyethylene windows caused interference fringes in the transmission spectra which, however, do not change the level of transmission. We used a transparent sample of 5 mm diameter, producing enough signal even at the lowest frequencies where transmission was low. The spectra were reproducible during several cooling and heating cycles.

In the usual analysis of visible/near-IR spectra, one calculates the extinction ($-\ln T$ or $-\log T$) from the transmission and calls this quantity the absorbance, or the product of absorption coefficient times thickness, without making further corrections. For many materials this method is perfectly adequate, as the amount of light reflected by the sample is small and only weakly dependent on wavelength. However, this procedure is not justified for strongly absorbing materials; in these the reflection (and its wavelength dependence) is a major factor, indeed often the dominant one, in determining the light transmission. This situation is the case in nanotube samples at low frequencies. Therefore, we determined the optical functions by Kramers-Kronig analysis of the transmittance.

Kramers-Kronig analysis is not as commonly applied to transmittance as it is to reflectance. Nevertheless, the transmittance of a film is subject to the same causality restrictions as the reflectance; consequently, one may estimate the phase shift on transmittance from a Kramers-Kronig integral, much as one does for reflectance. The procedure requires free-standing, uniform-thickness films, wide spectral coverage, and reasonable photometric accuracy, $\mathcal{O}(1\%)$. The relationship between the phase shift $\Theta(\omega)$ and the transmittance $T(\omega)$ may be written in the following illuminating form:

$$\Theta(\omega) = -\frac{1}{2\pi} \int_0^\infty \ln \left| \frac{s + \omega}{s - \omega} \right| \frac{d \ln T(s)}{ds} ds. \quad (1)$$

According to Equation 1, spectral regions in which the transmittance is constant do not contribute to the integral. Further, the spectral regions $s \gg \omega$ and $s \ll \omega$ do not contribute much because the function $\ln |(s + \omega)/(s - \omega)|$ is small in these regions.

Formally, the phase-shift integral requires knowledge of the transmittance at all frequencies. In practice, one obtains the transmittance over as wide a frequency range as possible and then completes the transform by extrapolating the transmittance to frequencies above and below the range of the available measurements. The conventional low-frequency extrapolation for metals is $T(\omega) = T(0) + A\omega^2$, where A is a constant determined by the transmittance at the lowest frequency measured in the experiment and $T(0)$ is the extrapolated behavior to zero frequency, determined by the dc conductivity. The high-frequency extrapolation uses $T = 1 - C\omega^{-n}$ with $n \approx 1$ and C chosen to give a smooth connection to the high-frequency transmittance curve.

After computing the phase, one may extract the complex refractive index N (and all other optical constants) by numerical solution of¹⁴

$$\sqrt{T}e^{i\Theta} = \frac{4N}{(N+1)^2e^{-i\delta} - (N-1)^2e^{i\delta}}, \quad (2)$$

where $\delta = \omega Nd/c$ with d the film thickness. An important detail is that the phase gained by the radiation in passing through a thickness d of vacuum must be added to δ before calculating N . Equation 2 includes of course interfacial reflections, including multiple reflections within the sample.

III. RESULTS

Figure 1 shows the room-temperature transmission, optical conductivity and calculated absorbance spectra before and after baking. Above 4000 cm^{-1} , the absorption coefficients calculated from the Kramers-Kronig transformation agree with $(-\ln T)$.

The absorption coefficient of the material is the absorbance per unit thickness; to obtain absorption coefficients in units of $\text{cm}^2/(\text{mole C})$, we have to divide by the density. We determined the density of our materials directly by weighing a piece whose thickness was measured by atomic force microscopy, and obtained 0.4 g/cm^3 . Our absorption values are higher than those found by Zhao *et al.*¹⁵ in a comprehensive study of various nanotubes. They found $\alpha(S_{22})$ of $0.6\text{--}1.1 \cdot 10^6$ (in our units), compared with our value (in the baked samples) of $1.8\text{--}1.9 \cdot 10^6$. One reason for the difference may be that in our films the long axes of the tubes are largely aligned in the plane of the film, whereas in solution spectroscopy they are disordered in three dimensions.

We also performed a Drude-Lorentz fit to the transmission curves, using the Airy formula¹⁴ for the transmittance of a thin, free-standing film. Table II lists the fitting parameters obtained. The fits and the contributions of individual oscillators to the optical conductivity at 300 K are illustrated in Fig. 2. We used only electronic oscillators to model the spectra; no vibrational transitions are discernible in the baked samples, even after the baseline correction described recently by Kim *et al.*¹⁶ In the doped materials, we observed the weak vibrational peaks seen by Hennrich *et al.*;¹² these disappear on baking.

The conductivity and the absorbance are independent of thickness except at very low frequencies; even there, the values are comparable.

IV. DISCUSSION

A. Baked (undoped) samples

We discuss first the room-temperature results on the baked samples, because we regard these as closest to pris-

TABLE II: Drude-Lorentz fit parameters (plasma frequency (ω_{pi}), center frequency (ω_i) and width (γ_i) in cm^{-1}) for each sample studied at several temperatures. For peak 0, the free-carrier (Drude) absorption, the center frequency is 0. The starting parameters for high-frequency oscillators were taken from Ref. 17. The high-frequency dielectric constant is 1.04.

		ω_{p0}	γ_0	ω_{p1}	ω_1	γ_1	ω_{p2}	ω_2	γ_2	ω_{p3}	ω_3	γ_3	ω_{p4}	ω_4	γ_4
Sample A	300 K	2057	762	4055	35	128	3419	6189	1435	5268	10616	3888	2505	14884	2199
doped															
Sample B	50 K	1817	2555	3257	58	154	4613	5913	1298	4105	10429	2587	1689	14763	1310
de-doped	100 K	1927	2661	3258	56	158	4615	5911	1308	4079	10436	2552	1721	14771	1342
	200 K	1863	2250	3242	65	166	4573	5913	1277	4085	10424	2597	1676	14764	1306
	300 K	1926	2232	3226	66	187	4600	5910	1310	4076	10435	2571	1725	14772	1355
Sample C	100 K	2314	3393	4408	0	134	2296	6245	1648	4074	10859	3591	2674	15400	3880
most doped	200 K	2318	2944	4381	0	139	2318	6241	1679	4083	10868	3603	2646	15402	3802
	300 K	2302	2509	4337	0	144	2328	6244	1655	4114	10858	3624	2646	15380	3793
Sample C'	100 K	1984	2136	2904	20	122	4044	5937	1176	4459	10442	3122	1937	15136	1977
de-doped	200 K	2220	2307	2917	20	131	4037	5919	1162	4502	10410	3187	1975	15194	2014
	300 K	2561	2442	2917	20	140	4206	5935	1230	4520	10436	3160	1756	15194	1585

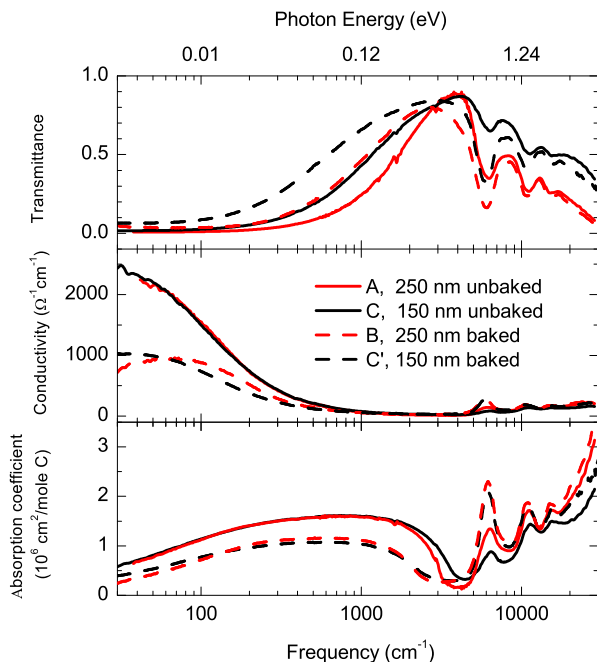


FIG. 1: (color online) Transmittance, optical conductivity and absorption coefficient of two SWNT transparent films of different thickness.

tine carbon nanotubes. Optical spectroscopy is routinely used for purity evaluation of nanotube samples^{15,18} where the amount of amorphous carbon is deduced from the background absorption in the near infrared. Comparing our spectra with those by Zhao *et al.*¹⁵ we estimate the purity to equal those of their best samples. We assume the films dense and isotropic enough to apply a model of a continuous medium. (Effective-medium models have been employed for polarized measurements where the shape of the tubes is crucial.¹⁹)

The low-frequency conductivity can be best described by a two-component model. In Sample B, the two components consist of a Drude free-electron contribution and a Lorentzian peak centered near 0.01 eV. In Sample C', we found that a fit with two Drude contributions, with distinct damping constants, also described the data. We note, however, that if the center frequency of the Lorentzian shifts below the measured range ($\sim 30 \text{ cm}^{-1}$), then it is essentially indistinguishable from a Drude curve. Indeed, an equally good fit is obtained if we fix the frequency of this peak at 20 cm^{-1} (close to that observed by Terahertz spectroscopy¹⁹). We can also compare our data to those of Hilt *et al.*²⁰ measured at Terahertz frequencies in similar laser-ablated nanotubes as used in the present study. Although the exact doping level of the tubes studied there is not known, they also find a narrow Drude component and a broad absorption, modeled as a constant background conductivity in their restricted frequency range.

Thus we assign the Drude part to truly metallic tubes and the low-frequency Lorentzian to the curvature-induced gap suggested by Kane and Mele⁷ and observed in individual nanotubes by scanning tunneling spectroscopy.²¹ In our samples, this gap actually represents an average of gaps for “semimetallic” tubes of different diameter and chirality.²² Note that the width (γ) of the Drude contribution is typically more than ten times the width of the low-energy Lorentzian, suggesting that the mobility of carriers in semiconducting tubes is much higher than in metallic tubes.

The origin of the variation among samples can be attributed to unintentional doping by atmospheric oxygen.^{23,24} A modest number of extra holes is enough to smear out the gaps of some of the nanotubes and change their distribution, shifting the median to lower energies. The fact that the thinner film (Sample C') appears more doped is in accordance with observations by Collins *et*

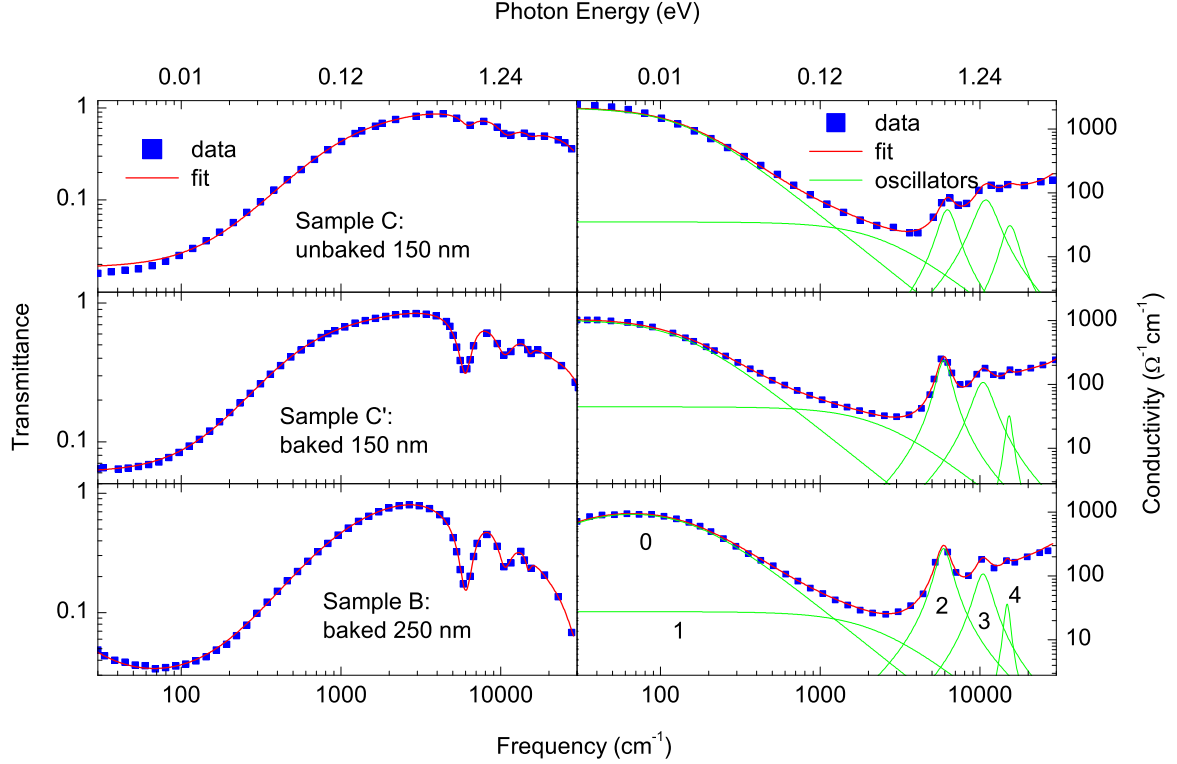


FIG. 2: (color online) The results of Drude-Lorentz fits (least-squares fits to transmission curves) compared to measured room-temperature transmission data and to conductivity obtained by Kramers-Kronig transformation. Numbers refer to oscillator labels in Table II.

*al.*²⁴ We see no indication of the bundle-induced pseudogap at 0.1 eV seen in Ref. 21. The disappearing of the pseudogap was predicted by Maarouf *et al.*⁹ for macroscopic samples with compositional disorder.

The temperature dependence of the conductivity is much weaker than that of a simple metal (see Fig. 3). It is confined largely to the far infrared. The low-frequency conductivity decreases with increasing temperature; a crossover at 120 cm^{-1} reverses this dependence up to about 2000 cm^{-1} , where it becomes too weak to be observed. The fits to a dielectric function model (Table II) show a slight broadening of peak 1, along with a blue shift of the low-frequency peak in Sample B. We saw no indication down to 50 K for a sudden conductivity drop, which is expected if a Luttinger liquid state develops.²⁵

The low-frequency optical conductivity of the baked samples, 800 and 1000 $\Omega^{-1}\text{cm}^{-1}$ for Samples B and C', respectively, agree well with the 700 $\Omega^{-1}\text{cm}^{-1}$ value determined from sheet resistance.¹ The 2600 $\Omega^{-1}\text{cm}^{-1}$ dc conductivity of the unbaked sample is somewhat lower than that determined by direct sheet resistance measurements (6700 $\Omega^{-1}\text{cm}^{-1}$) (and closer to the value 2900 $\Omega^{-1}\text{cm}^{-1}$ obtained by Liu *et al.*²⁶ for FeCl_3 doped nanotubes from EELS results) but the trend of higher conductivity in the unbaked samples is clear.

B. Unbaked (doped) samples

We now turn to the effect of doping on the optical properties. Figure 1 demonstrates that nitric acid doping increases the conductivity in the far infrared and decreases it around the first Van Hove transition. At low frequencies, the narrower band (the one at finite frequency in Sample B) is much more influenced than the broad Drude part. We can directly compare the parameters of Sample C (doped) and C' (undoped): as a general trend, peak 0 and peak 1 both increase in intensity on doping, peak 1 more so than peak 0, while peak 2 and peak 3 (the semiconductor tubes' S_{11} and S_{22} transitions, respectively) decrease. Peak 2 and peak 3 also shift to higher energies, as already reported by Itkis *et al.*⁶ The high-frequency changes upon doping have been reported and explained extensively.^{27,28} On hole doping, metallic tubes get depleted of charge and therefore a slight decrease in their contribution to the low frequency conductivity is expected. In semiconductors a redistribution of oscillator strength occurs as the highest-lying valence band loses electrons. This change in the occupation of states leads to a decrease of the S_{11} interband transition (peak 2) and at the same time, an increase in the low-frequency conductivity. The fact that this distribution strengthens peak 1 indicates that the doped semiconducting tubes also can be regarded as semimetals. At

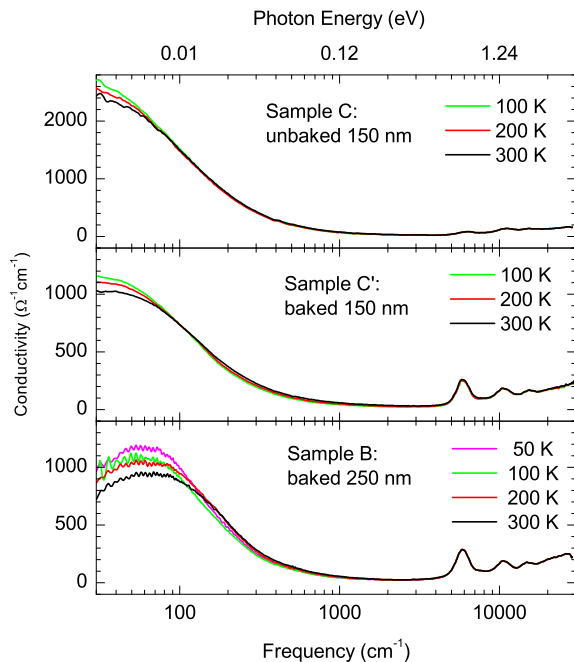


FIG. 3: (color online) Temperature dependence of the optical conductivity of the two samples.

higher doping level, the same scenario occurs at the second interband transition.

The top panel of Fig. 4 shows the partial sum rule for Samples C and C'. This quantity is obtained by integrating $\sigma_1(\omega)$ from $\omega = 0$ to an upper frequency, and plotting the integrated weight versus the upper limit, representing the effective number of carriers per C atom taking part in optical transitions below the upper-limit frequency. Up to the near infrared, the hole-doped material shows a much higher weight than the de-doped one; at higher frequencies the difference changes sign. The middle and bottom panels of Figure 4 show respectively the difference in spectral weight and the difference in conductivity $\Delta\sigma_1$ between the doped and undoped samples. The behavior may be divided into three regions: the free-carrier part (region I), the interband transition part (region II) and the π -electron excitation part (region III). The boundary between regions I and II is at 1765 cm^{-1} , where the conductivity difference changes sign (bottom panel): we assume that if we had a series of concentrations, this point would be isosbestic. The sum rule difference in this part of the spectrum (middle panel) levels off at the value of 0.005 e/C , before it starts to decrease at the S_{11} transition. A second, smaller, negative peak in the conductivity can be seen at the S_{22} frequency. We put the boundary between regions II and III at $12,600 \text{ cm}^{-1}$, where $\Delta\sigma_1$ approaches zero again, and the value of the sum rule reaches -0.005 e/C . We infer from this that the principal effect of hole doping is a redistribution

of charge within the semiconducting nanotubes, and the doping of the metallic tubes is negligible in comparison. In region III the collective excitations of π -electrons can

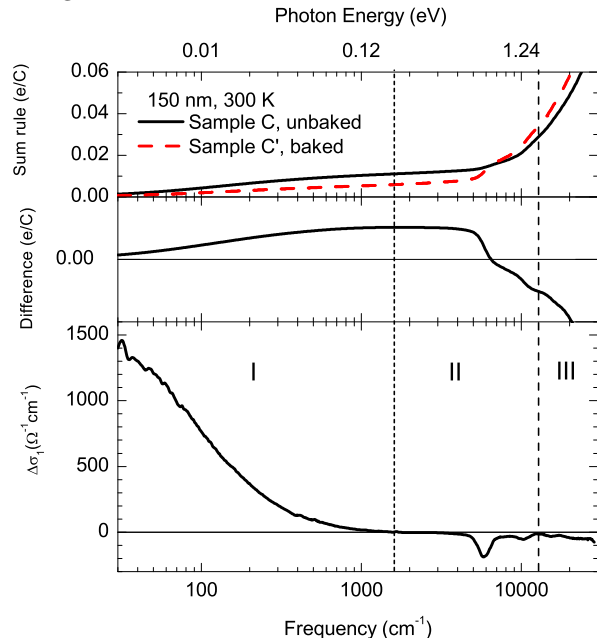


FIG. 4: (color online) Top panel: sum rule for baked and unbaked sample at 300 K. Middle panel: added carriers per carbon as function of frequency at selected temperatures. Bottom panel: difference in conductivity upon doping. For the definition of regions I, II, and III, see text.

be found.²⁹

V. SUMMARY

In summary, we have presented optical transmission in a wide frequency and temperature range of high-quality transparent single-walled carbon nanotube films. We found a gap feature below 10 meV and associate it with the curvature-induced gap of semimetallic tubes. We estimate the hole doping of our samples by nitric acid to cause a 0.005 e/C redistribution of charge between the free-carrier absorption and the interband transitions in semiconducting tubes and suggest that the free carriers in the doped semiconductors behave similarly to those in semimetallic tubes.

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- ¹ Z. Wu, Z. Chen, X. Du, J. Logan, J. Sippel, M. Nikolou, K. Kamarás, J. R. Reynolds, D. B. Tanner, A. F. Hebard, and A. G. Rinzler, *Science* **305**, 1273 (2004).
 - ² H. Kataura, J. Kumazawa, Y. Maniwa, I. Umez, S. Suzuki, Y. Ohtsuka, and Y. Achiba, *Synth. Met.* **103**, 2555 (1999).
 - ³ M. J. O'Connell, S. M. Bachilo, C. B. Huffman, V. C. Moore, M. S. Strano, E. H. Haroz, K. L. Rialon, P. J. Boul, W. H. Noon, C. Kittrell, J. Ma, R. H. Hauge, R. B. Weissman, and R. E. Smalley, *Science* **297**, 593 (2002).
 - ⁴ A. Ugawa, A. G. Rinzler, and D. B. Tanner, *Phys. Rev. B* **60**, R11305 (1999).
 - ⁵ A. Ugawa, J. Hwang, H. H. Gommans, H. Tashiro, A. G. Rinzler, and D. B. Tanner, *Curr. Appl. Phys.* **1**, 45 (2001).
 - ⁶ M. E. Itkis, S. Niyogi, M. E. Meng, M. A. Hamon, H. Hu, and R. C. Haddon, *Nano Lett.* **2**, 155 (2002).
 - ⁷ C. L. Kane and E. J. Mele, *Phys. Rev. Lett.* **78**, 1932 (1997).
 - ⁸ P. Delaney, H. J. Choi, J. Ihm, S. G. Louie, and M. L. Cohen, *Nature* **391**, 466 (1998).
 - ⁹ A. A. Maarouf, C. L. Kane, and E. J. Mele, *Phys. Rev. B* **61**, 11156 (2000).
 - ¹⁰ J. Hwang, H. H. Gommans, A. Ugawa, H. Tashiro, R. Haggemueller, K. I. Winey, J. E. Fischer, D. B. Tanner, and A. G. Rinzler, *Phys. Rev. B* **62**, R13310 (2000).
 - ¹¹ F. Hennrich, S. Lebedkin, S. Malik, J. Tracy, M. Barczewski, H. Rösner, and M. Kappes, *Phys. Chem. Chem. Phys.* **4**, 2273 (2002).
 - ¹² F. Hennrich, R. Wellmann, S. Malik, S. Lebedkin, and M. M. Kappes, *Phys. Chem. Chem. Phys.* **5**, 178 (2003).
 - ¹³ A. G. Rinzler, J. Liu, H. Dai, P. Nikolaev, C. B. Huffman, F. J. Rodriguez-Macias, P. J. Boul, A. H. Lu, D. Heymann, D. T. Colbert, R. S. Lee, J. E. Fischer, A. M. Rao, P. C. Eklund, and R. E. Smalley, *Appl. Phys. A* **67**, 29 (1998).
 - ¹⁴ M. Dressel and G. Grüner, *Electrodynamics of solids* (Cambridge University Press, 2002).
 - ¹⁵ B. Zhao, M. E. Itkis, S. Niyogi, H. Hu, J. Zhang, and R. C. Haddon, *J. Phys. Chem. B* **108**, 8136 (2004).
 - ¹⁶ U. J. Kim, X. M. Liu, C. Furtado, G. Chen, R. Saito, J. Jiang, M. S. Dresselhaus, and P. C. Eklund, *Phys. Rev. Lett.* **95**, 157402 (2005).
 - ¹⁷ Y. Murakami, E. Einarsson, T. Edamura, and S. Maruyama, *Phys. Rev. Lett.* **94**, 087402 (2005).
 - ¹⁸ M. E. Itkis, D. E. Perea, S. Niyogi, S. M. Rickard, M. A. Hamon, H. Hu, B. Zhao, and R. C. Haddon, *Nano Lett.* **3**, 309 (2003).
 - ¹⁹ T.-I. Jeon, K.-J. Kim, C. Kang, I. H. Maeng, J.-H. Son, K. H. An, J. Y. Lee, and Y. H. Lee, *J. Appl. Phys.* **95**, 5736 (2004).
 - ²⁰ O. Hilt, H. B. Brom, A. Ugawa, and M. Ahlsgog, *Phys. Rev. B* **61**, R5130 (2000).
 - ²¹ M. Ouyang, J.-L. Huang, C. L. Cheung, and C. M. Lieber, *Science* **292**, 702 (2001).
 - ²² A. Ugawa, A. G. Rinzler, and D. B. Tanner, *Ferroelectrics* **249**, 145 (2001).
 - ²³ G. U. Sumanasekera, C. K. W. Adu, S. Fang, and P. C. Eklund, *Phys. Rev. Lett.* **85**, 1096 (2000).
 - ²⁴ P. G. Collins, K. Bradley, M. Ishigami, and A. Zettl, *Science* **287**, 1801 (2000).
 - ²⁵ H. Ishii, H. Kataura, H. Shiozawa, H. Yoshioka, H. Otsubo, Y. Takayama, T. Miyahara, S. Suzuki, Y. Achiba, M. Nakataka, T. Narimura, M. Higashiguchi, K. Shimada, H. Namatame, and M. Taniguchi, *Nature* **426**, 540 (2003).
 - ²⁶ X. Liu, T. Pichler, M. Knupfer, J. Fink, and H. Kataura, *Phys. Rev. B* **70**, 205405 (2004).
 - ²⁷ S. Kazaoui, N. Minami, R. Jacquemin, H. Kataura, and Y. Achiba, *Phys. Rev. B* **60**, 13339 (1999).
 - ²⁸ P. Petit, C. Mathis, C. Journet, and P. Bernier, *Chem. Phys. Lett.* **305**, 370 (1999).
 - ²⁹ T. Pichler, M. Sing, M. Knupfer, M. S. Golden, and J. Fink, *Solid State Commun.* **109**, 721 (1999).